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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/823,759	04/14/2004	Kuo-Rong Chen	OP-093000122	5064
7590 Yi-Wen Tseng 4331 Stevens Battle Lane Fairfax, VA 22033	03/19/2007		EXAMINER SANAI, HANA ASMAT	
			ART UNIT 2879	PAPER NUMBER
SHORTENED STATUTORY PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE		
3 MONTHS	03/19/2007	PAPER		

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

Office Action Summary	Application No.	Applicant(s)	
	10/823,759	CHEN ET AL.	
Examiner	Art Unit		
Hana A. Sanei	2879		

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

1) Responsive to communication(s) filed on 08 February 2007.

2a) This action is **FINAL**. 2b) This action is non-final.

3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

4) Claim(s) 1, 11-18 is/are pending in the application.
4a) Of the above claim(s) 11-17 is/are withdrawn from consideration.
5) Claim(s) _____ is/are allowed.
6) Claim(s) 1, 18 is/are rejected.
7) Claim(s) _____ is/are objected to.
8) Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

9) The specification is objected to by the Examiner.

10) The drawing(s) filed on 14 April 2004 is/are: a) accepted or b) objected to by the Examiner.

Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).

Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).

11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
a) All b) Some * c) None of:
1. Certified copies of the priority documents have been received.
2. Certified copies of the priority documents have been received in Application No. _____.
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

1) Notice of References Cited (PTO-892)
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)
3) Information Disclosure Statement(s) (PTO/SB/08)
Paper No(s)/Mail Date _____

4) Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____

5) Notice of Informal Patent Application

6) Other: _____

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 2/8/07 has been entered.

Cancellation of Claims 2-10 is entered.

Claims 1, 11-18 are pending in the instant application.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

and 3/15/07

Claims 1, 18 are rejected under 35 U.S.C. 102(b) as being anticipated by Tomii et al (US 5160871).

Regarding Claim 1, Tomii teaches a first conductive layer (215, focusing electrode, see at least Fig. 7) to serve as a converging electrode layer having a proximal surface facing the anode units (216) and a distal surface opposing to the proximal surface, the first conductive layer comprising a plurality of first apertures (219) extending therethrough, a glass plate formed (231, 232, glass, Col. 8, lines 60-64, Fig.

9) on the proximal surface of the first conductive layer, the glass plate including a plurality of second apertures (partitioning of 231, 232, see Fig. 9) extending therethrough and each second aperture covering a row or a column of the first apertures (the partitioning of 231, 232 covers at least a portion of "a row or a column"), an insulation layer (231') formed on the distal surface of the first conductive layer, a second conductive layer (213, gate electrode) formed on the insulation layer to serve as a gate electrode layer, the second conductive layer having a proximal surface facing the cathode units (212) and a distal surface opposing the proximal surface, wherein the second conductive layer includes a plurality of third apertures (218) extending therethrough and aligned with the first and second apertures, and each third aperture covers a row or a column of the first aperture (218 covers at least a portion of "a row or a column"), wherein a plurality of isolation slits (strips of 213) extend across the second conductive layer so that a pair of conductive strips are formed at two elongated sides of each third aperture, each pair of the conductive strips constructs an independent conductive paths to be biased with a potential and a gate operative to drain electrons from the cathode unit between the pair of conductive strips is formed (see at least Fig. 7).

Regarding Claim 18, Tomii teaches that each first aperture (219, refer to Fig. 9) is aligned with a corresponding anode unit (216 M) with a phosphor layer (216P, R-G-B) and a cathode unit (211) with an emission layer (212).

Contact Information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hana A. Sanei whose telephone number is (571) 272-8654. The examiner can normally be reached on Monday- Friday, 9 am - 5 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nimeshkumar D. Patel can be reached on (571) 272-2457. The fax phone number for the organization where this application or proceeding is assigned is (571) 273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).


Hana A. Sanei
Examiner


Joseph Williams
Primary Examiner